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		U	.S. PAT	ENT DOCUMENTS				
				December 27, 2004	1637			
FORM PTO-1449 INFORMATION DISCLOSURE CITATION				Filing Date:	_	Group Art Unit:		
				Hiroyuki HASHIMOTO et al.				
				Applicant:				
				1004288.55700 10/519,813				
				Attorney Docket:	Serial N	lo.:		

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Examiner Initial	Patent Number	Publication Date	Country	Class	Sub-Class	Translation
NA DESCRIPTION OF THE PROPERTY			•			☐ Yes ☐ No
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				CONTRACTOR OF THE PROPERTY OF		☐ Yes ☐ No
			Country		COLORDO DO	☐ Yes ☐ No

	OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Papers, etc.)					
/TS/	Yu Wei, et al., "Preparation and Morphology Characterization of Solid and Functionalized Layer of Immune Molecules," Vol. 19, No. 6, pgs. 373-374 (2001) (English Translation).					
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/TS/	Notification of the Second Office Action which was cited in a corresponding Chinese counterpart application No. 038151014, date of issue: January 9, 2009					
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	038151014, date of issue: January 9, 2009					

Examiner	/Teresa Strzelecka/	Date Considered	07/25/2009		
EXAMINER:	Initial if reference considered, whether or not citation is in conformance with MPEP §609.				
	Draw line through citation if not in conformance and not considered.				
	Include copy of this form with next communication to Applicant.				